

# Additional modeling comparing Hamamatsu and Broadcom SiPM for HEP PWO readout

Consider 20% optical coupling efficiency between PWO and SiPM to estimate non-linearity

# Modeling computation (energy linearity)

- Estimate the number of cells firing from incident particle
- Compute integral non-linearity at 15GeV
- Photon collection from crystal to SiPM? Use 100% and 20% (more realistic)

$$N_{\text{fired}}(M, V, \lambda) = M \cdot \left\{ 1 - \exp \left[ - \frac{PDE(V, \lambda) \cdot N_{ph}}{M} \right] \right\}$$

$N_{\text{fired}}$  = number of activated cells

$M$  = total number of cells

$PDE(V, \lambda)$  = photodetection efficiency

$V$  = bias voltage,  $\lambda$  = photon wavelength

$N_{ph}$  = number of incident photons

	Hamamatsu S14160-3010	Onsemi 60035	Hamamatsu S14160-3015	Broadcom AFBR-S4N44C013	Broadcom AFBR-S4N44P014M
Total number of cells	89984	22292	39984	15060	8334
Incoming Particle energy (eV)	1.50E+10	1.50E+10	0	1.50E+10	1.50E+10
Scintillator light yield (ph/eV)	1.50E-05	1.50E-05	1.50E-05	1.50E-05	1.50E-05
N photon / incoming particle	2.25E+05	2.25E+05	5	2.25E+05	2.25E+05
Crystal surface area (mm <sup>2</sup> )	400	400	400	400	400
Nflux (ph/mm <sup>2</sup> )	563	563	563	563	563
Nb of SiPM	16	9	16	16/25	16
SiPM active area (mm <sup>2</sup> )	9	37	9	13.84	13.47
Nph for one SiPM	5063	20725	5063	7784.1	7575
Include fill factor to Nph	1569	15544	2481	4687	5757
Nb of activated sites/SiPM	907	6635	1588	3001	3633
INL at 15GeV	0.18%	10.69%	1.26%	8.21%	24%
Total activated cells	14506	59713	25402	48021	58131
Resolution (bit)	14	16	15	16	16
INL at 15GeV 20% coupling efficiency	0.04%	2.56%	0.26%	1.85%	6.59%
Total activated cells	2913	13687	5163	10476	14428
Resolution (bit)	12	14	13	14	14

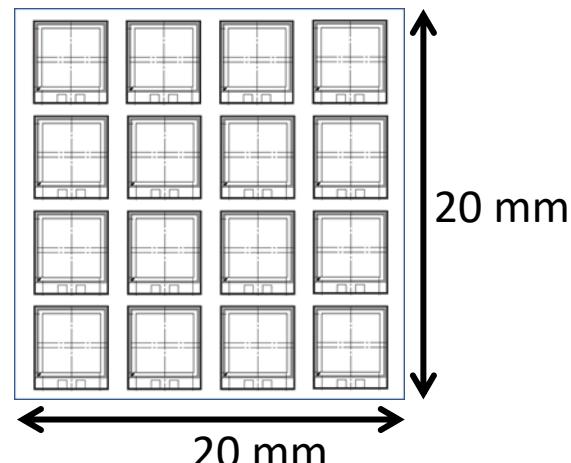
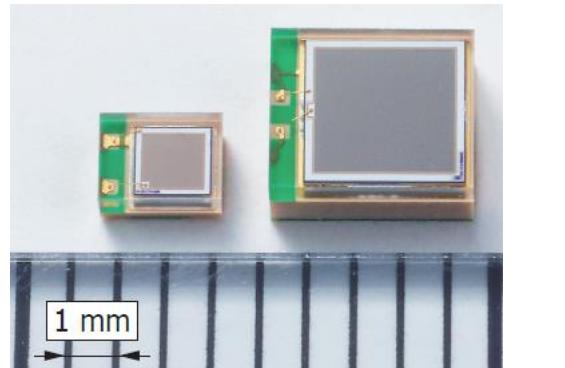
Best compromises

# Hamamatsu S14160-3015

- 3 mm x 3 mm active
- PDE 32% (at 420 nm)
- 15  $\mu\text{m}$  microcells
- Anode capacitance 530 pF
- Dark count rate 700kcps (typ.)
- VOP variation within reel  $\pm 0.1\text{V}$  ( $\pm 8\%$  gain)

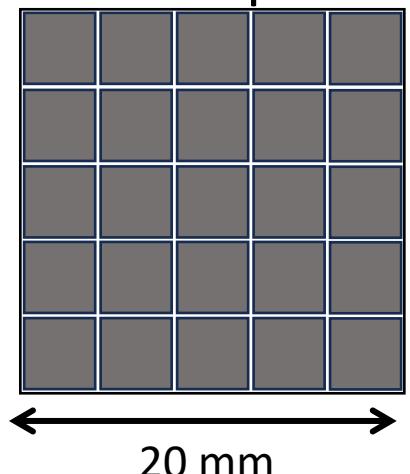
- 16 pcs to fill 20 mm x 20 mm
- Active fill: 36% of area
- Rough computation for # activated cells for 15GeV deposited in crystal: 5,160 (20% coupling eff.)
- Expected Integral Non-linearity at 15GeV: 0.26% (20% coupling eff.)
- Measured fast timing (70ns FWHM)

16 x 3015



# Broadcom AFBR-S4N44C013

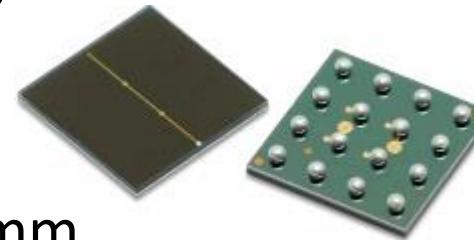
- 3.72 mm x 3.72 mm active
- PDE 43/55% (420 nm) (typ./perf.)
- 30 µm microcells
- Anode capacitance 990/760 pF (typ./perf.) slightly longer pulse
- Dark count rate 1660 kcps (typ.)



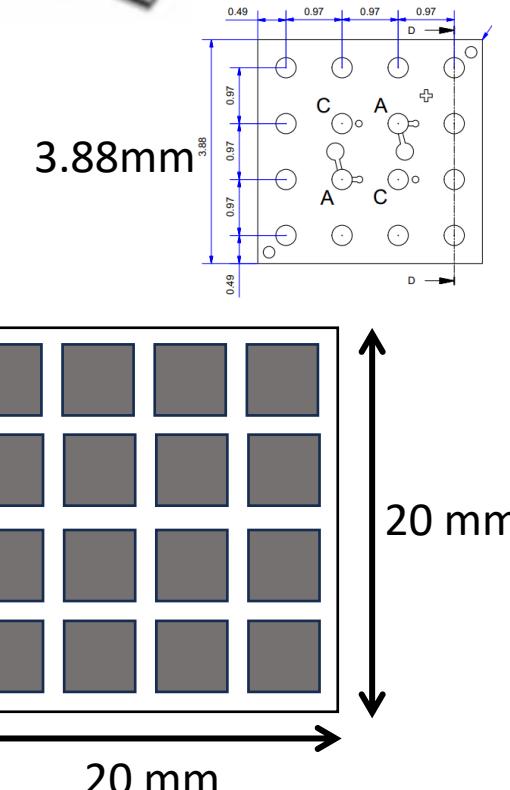
20 mm

5x5 matrix for area coverage is possible  
86% active coverage (better than PMT)

- 16/25 pcs to fill 20 mm x 20 mm
- Active fill: 55/86% of area
- Rough computation for # activated cells for 15GeV deposited in crystal: 10,476 (20% coupling eff.)
- Expected Integral Non-linearity at 15GeV: 1.85% (20% coupling eff.)



16 x S4N44C013



# Expected resolution with different SiPMs

- Use measured resolution from experiment as reference
- Compute relative signal level from change in PDE and active area
- Compute resolution change (1rst order scales with square root of signal)

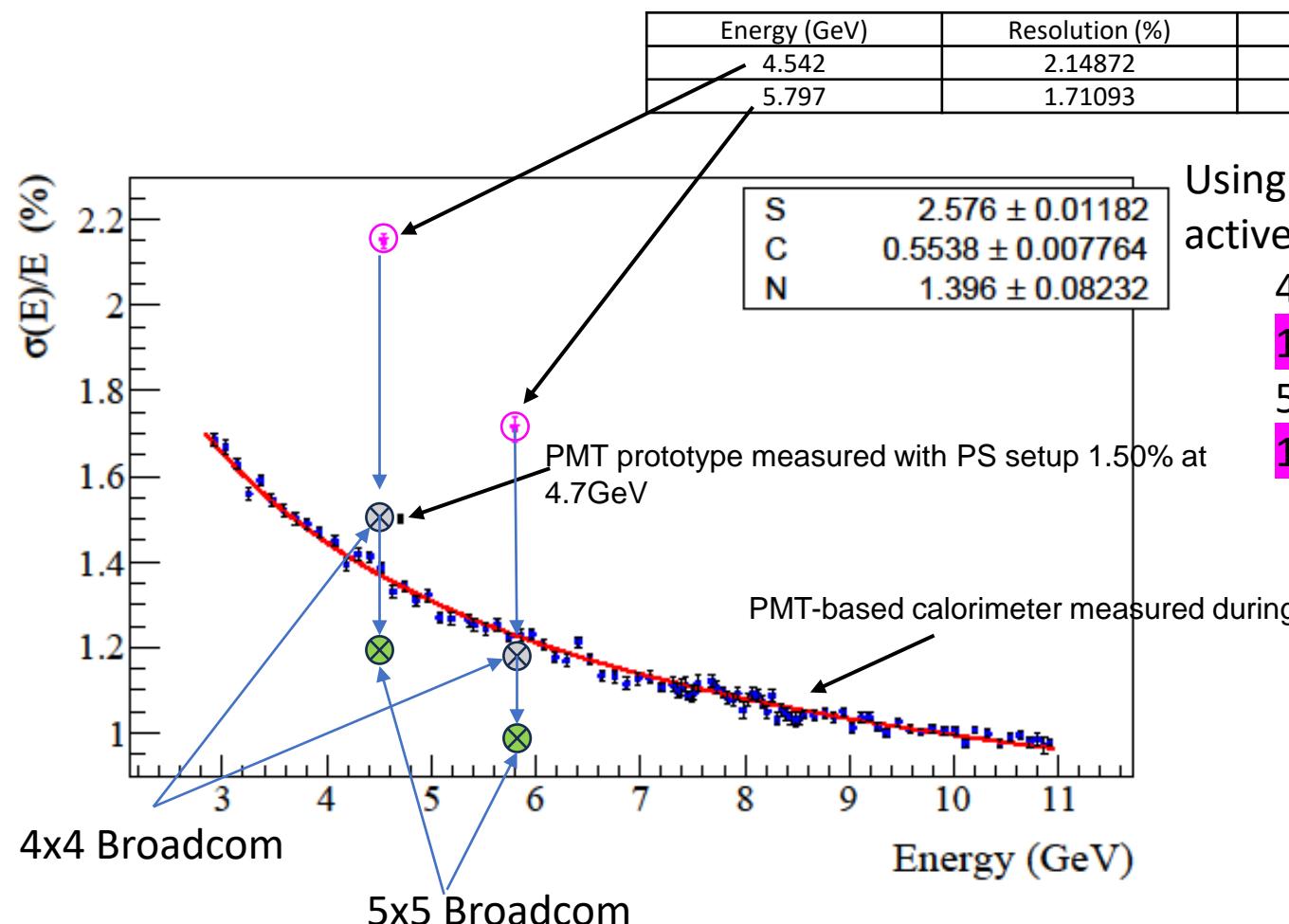
	Hamamatsu 14160-3010	Hamamatsu 14160-3015	Hamamatsu 14160-6015	Hamamatsu 14160-6010	Broadcom AFBR-S4N44C013	Broadcom AFBR-S4N44C013	Broadcom AFBR-S4N44P014M	PMT Hamamatsu R4125 (19mm dia, 15mm cathode)
configuration	4x4	4x4	2x2	2x2	4x4	5x5	4x4	1
PDE (% 420nm)	17	30	30	17	43	43	63	27
active fill (%)	36	36	36	36	55	86	54	71
relative signal level (100%)	57	100	100	57	219	342	314	177
expected resolution at 4.54 GeV (%)	<b>2.86</b>	<b>2.15</b>	<b>2.15</b>	<b>2.86</b>	<b>1.45</b>	<b>1.16</b>	<b>1.21</b>	<b>1.62</b>
expected resolution at 5.8 GeV (%)	<b>2.27</b>	<b>1.71</b>	<b>1.71</b>	<b>2.27</b>	<b>1.16</b>	<b>0.92</b>	<b>0.96</b>	<b>1.28</b>

Measured at JLab w. 3x3 Crytur prototype 2.0

predicted

Predicted PMT resolution:  
**1.59%** at 4.7GeV  
Measurement: **1.5%**  
3x3 PMT based detector  
measured at JLAB

# Energy resolution: comparison with PMT

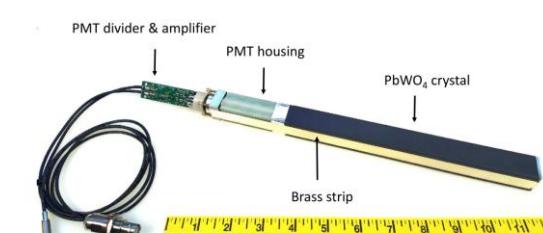


Energy (GeV)	Resolution (%)	Res_error
4.542	2.14872	0.01644
5.797	1.71093	0.02872

Using Broadcom AFBR-S4N44C013 w. higher PDE and active area

4x4 array res. 4.54 GeV 2.15%  $\rightarrow$  1.45%; 5.8 GeV  
1.71%  $\rightarrow$  1.16%

5x5 array res. 4.54 GeV 2.15%  $\rightarrow$  1.16%; 5.8 GeV  
1.71%  $\rightarrow$  0.92%



Hamamatsu 4125

# Summary table

	Hamamatsu 14160-3010	Hamamatsu 14160-3015	Hamamatsu 14160-6015	Hamamatsu 14160-6010	Broadcom AFBR- S4N44C013	Broadcom AFBR- S4N44C013	Broadcom AFBR- S4N44P014M	PMT Hamamatsu R4125 (19mm dia, 15mm cathode)
Cell pitch ( $\mu\text{m}$ )	10	15	15	10	30	30	40	15000
Capacitance (pF)	530	530	2500	2500	990/760	990/760	580	
PDE at 420nm (%)	17	30	30	30	43/55	43/55	63	27
configuration	4x4	4x4	2x2	2x2	4x4	5x5	4x4	1
PDE (% 420nm)	17	30	30	17	43	43	63	27
active fill (%)	36	36	36	36	55	86	54	71
relative signal level (100%)	57	100	100	57	219	342	314	177
expected resolution at 4.54 GeV (%)	2.86	2.15	2.15	2.86	1.45	1.16	1.21	1.62
expected resolution at 5.8 GeV (%)	2.27	1.71	1.71	2.27	1.16	0.92	0.96	1.28

PMT: 1.59% at 4.7GeV  
Measurement: 1.5%

Significant resolution improvement, slight pulse timing and NL tradeoff